

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE



Re Application of:

STEVEN HANSEN

Confirmation No.

Application No.: 10/716,439

Group Art Unit:

Filed: November 20, 2003

Examiner:

Title: LITHOGRAPHIC APPARATUS AND METHOD FOR OPTIMIZING
AN ILLUMINATION SOURCE USING ISOFOCAL COMPENSATION

* * * *

February 20, 2004

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. BOX 1450
Alexandria, VA 22313-1450

Sir:

Pursuant to 37 CFR 1.56, the attention of the Patent and Trademark Office is hereby directed to the references listed on the attached PTO-1449. It is respectfully requested that the information be expressly considered during the prosecution of this application, and that the references be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

The undersigned respectfully notes that copies of U.S. references are not required in applications filed after June 30, 2003

This Information Disclosure Statement is being filed before the mailing date of the first Office Action on the merits in the present application. No certification or fee is required.

Respectfully submitted,

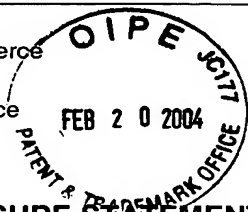
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**INFORMATION DISCLOSURE STATEMENT
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Date: February 20, 2004

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Atty.
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Client Ref.

304500

P-1503.001-US

Applicant: Steven HANSEN

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U.S. PATENT DOCUMENTS

Examiner's Initials*		Document Number	Date MM/YYYY	Name (Family Name of First Inventor)	Class	Sub Class	Filing Date (if appropriate)
	AR	5,523,193	06/1996	NELSON			
	BR	6,463,403 B1	10/2002	BURDORF et al.			
	CR	2002/0035461 A1	03/2002	CHANG et al.			
	DR	2002/0045106 A1	04/2002	BASELMANS et al.			
	ER	2002/0062206 A1	05/2002	LIEBCHEN			
	FR	2002/0152452 A1	10/2002	SOCHA			
	GR	2002/0167653 A1	11/2002	MULKENS et al.			
	HR	2003/0093251 A2	05/2003	CHANG			
	IR						
	JR						
	KR						
	LR						
	MR						
	NR						

FOREIGN PATENT DOCUMENTS

OVERVIEW INFORMATION							Abstract		Readily Available	
		Document Number	Date MM/YYYY	Country	Inventor Name		Enclosed	No	Enclose	No
	OR									
	PR									
	QR									
	RR									
	SR									
	TR									
	UR									
	VR									
	WR									
	XR									

OTHER (Including in this order Author, Title, Periodical Name, Date, Pertinent Pages, etc.)

	YR									
	ZR									
	AAR									
	BBR									
	CCR									
	DDR									

Examiner

Date Considered:

*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.